

ABSTRACT OF THE DISCLOSURE
MEASUREMENT APPARATUS, MEASUREMENT METHOD, EXPOSURE
METHOD, EXPOSURE APPARATUS AND ARTICLE MANUFACTURING
METHOD

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A measurement method of measuring a height position of a measurement region by irradiating the measurement region with light and detecting reflected light from the measurement region with a sensor, the method including obtaining information concerning a distribution of reflectances in the measurement region,
10 and setting a measurement target location in a region where the amount of reflected light detected by the sensor falls within a predetermined range in the measurement region based on the information.

(Figure 3)